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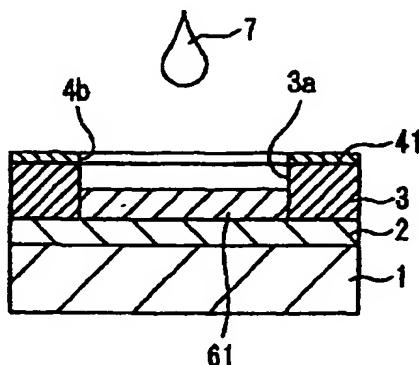
(54) Method of manufacturing organic EL element, organic EL element

(57) The invention seeks to ensure that a liquid is placed in a predetermined region (without being placed in an adjacent region) with a uniform thickness in the region, when a light emitting layer constituting an organic EL element is placed by, for example, ink jet process. Thin SiO₂ film pattern 3 having opening 3a is formed on ITO electrode 2. Next, ultrathin organic film pattern 41 is formed on ITO electrode 2.

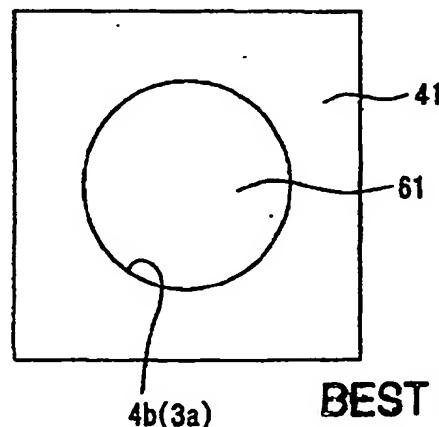
having opening 4b is formed on thin SiO₂ film pattern 3. The surface of ultrathin organic film pattern 41 becomes repellent to liquid. Hole transporting layer 61 is formed in opening 4b, and then liquid 7 containing a material for the formation of light emitting layer is discharged thereon by ink jet process. Fluid 7 does not remain on the surface of ultrathin organic film pattern 41 but enters opening 4b.

[FIG. 6]

(a)



(b)



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EUROPEAN SEARCH REPORT

Application Number
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<p>The present search report has been drawn up for all claims</p> <table border="1" style="width: 100%; border-collapse: collapse;"> <tr> <td style="width: 33%;">Place of search</td> <td style="width: 33%;">Date of completion of the search</td> <td style="width: 33%;">Examiner</td> </tr> <tr> <td>THE HAGUE</td> <td>1 April 2003</td> <td>De Laere, A</td> </tr> </table>				Place of search	Date of completion of the search	Examiner	THE HAGUE	1 April 2003	De Laere, A
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